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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant : Bong-Cheol Kim  
Serial No. : 10/089,479 Examiner: Nhu, David  
Filed : March 28, 2002 Group Art Unit: 2812  
For : APPARATUS AND METHOD FOR FORMING SINGLE  
CRYSTALLINE NITRIDE SUBSTRATE USING HYDRIDE  
VAPOR PHASE EPITAXY AND LASER BEAM

**SUPPLEMENTAL INFORMATION DISCLOSURE STATEMENT**

I hereby certify that this paper is being deposited with the United States  
Postal Service as first class mail in an envelope addressed to:  
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June 2, 2003

Date of Deposit

James J. Maune

Attorney Name

[Signature]  
Signature

26,946

PTO Registration No.

June 2, 2003

Date of Signature

Commissioner for Patents  
P.O. BOX 1450  
Alexandria, VA 22313-1450

Sir:

Pursuant to the provisions of 37 C.F.R. §§ 1.97 and 1.98, Applicant  
respectfully requests that the references relating to the above-mentioned application listed  
on attached PTO Form 1449, be made of record in the U.S. Patent and Trademark office.

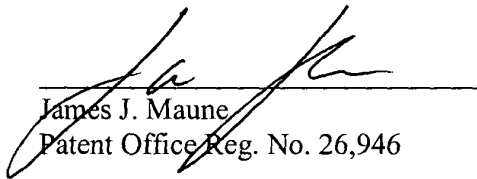
Copies of the referenced citations are enclosed. These documents were cited in the

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European Search Report, a copy of which is also enclosed, which was mailed on April 16, 2003.

No fee is believed to be required in connection with this communication. However, if a fee is required, the Commissioner is hereby authorized to charge the payment of any fees to Deposit Account No. 02-4377.

Respectfully submitted,



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Enclosures

